FORM: PTO 1449

Sheet: 1 of: 1

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FORM: PT@/1449	U.S. DEPARTMENT OF COMMERCE
REV. (180)	PATENT AND TRADEMARK OFFICE

Atty Docket No:
95-0392.02

Applicant:
Sandhu, et al.

Group:

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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(37°CFR 1.98(b))

(use several sheets if necessary)

November 12, 1999

## U.S. PATENT DOCUMENTS

				U.S. IAIBNI DOCUMENTO		
Examiner Initial		Document Number -	Date	Name	Class	Subclass
TOL	AA	5,824,607	10/20/98	Trow et al.	438	732
1	AB	5,817,534	10/06/98	Ye et al.	438	10
	AC	5,812,403	09/22/98	Fong et al.	364	468.28
	AD	5,792,272	08/11/98	van Os et al.	118	723 IR
	AE	5,788,799	08/04/98	Steger et al.	156	345
	AF	5,788,778	08/04/98	Shang et al.	134	001
	AG	5,614,055	03/25/97	Fairbairn et al.	156	345
	AH	5,514,246	05/07/96	Blalock	156	643.1
	AI	5,409,563	04/25/95	Cathey	156	643
	AJ	5,393,709	02/28/95	Lur et al.	437	228
	AK	5,389,496	02/14/95	Calvert et al.	430	315
	AL	5,389,195	02/14/95	Ouderkirk et al.	156	643
	AM	5,384,289	01/24/95	Westmoreland	437	245
	AN	5,368,687	11/29/94	Sandhu et al.	156	664
	AO	5,252,518	10/12/93	Sandhu et al.	437	200
	AP	5,240,739	08/31/93	Doan et al.	427	126.1
	AQ	4,878,994	11/07/89	Jucha et al.	156	643
1	AR	4,820,377	04/11/89	Davis et al.	156	643
$- \sqrt{-}$	AS	4,795,880	01/03/89	Hayes et al.	219	121.52

## FOREIGN PATENT DOCUMENTS

Examiner	Document		•			Trans	ation
Initial	Number	Date	Country	Class	Subclass	Yes	No
	AT						
	AU						

· Initial OTHER ART (including author, title, date, pertinent pages, etc.)

mmin	O I III (moradang dadior, title, date, pertinent pages, etc.)					
PL	AV — "Advanced Plasma Sources: What's Working?," Semiconductor International, pp. 56-58, 60, May 1984					
	AW					
	AX					

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Examiner: $\rho$ .	Hassanzodet	Date Considered:	3-31-04

**EXAMINER:** 

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